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(21) International Application Number: PCT/US97/18173 ✓ (22) International Filing Date: ✓ 7 October 1997 (07.10.97) ✓ (30) Priority Data: ✓ 60/027,303 ✓ 10 October 1996 (10.10.96) ✓ US ✓ (71) Applicant (for all designated States except US): RJR POLY- MERS INC. [US/US]; 7750 Edgewater Drive, Oakland, CA 94621 (US). ✓ (72) Inventor; and (75) Inventor/Applicant (for US only): ROSS, Richard, J. [US/US]; 504 Augusta Drive, Moraga, CA 94556 (US). ✓ (74) Agents: HEINES, M., Henry et al.; Townsend and Townsend and Crew LLP, 8th floor, Two Embarcadero Center, San Francisco, CA 94111 (US).			(81) Designated States: AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, CA, CH, CN, CU, CZ, DE, DK, EE, ES, FI, GB, GE, GH, HU, ID, IL, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MD, MG, MK, MN, MW, MX, NO, NZ, PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TR, TT, UA, UG, US, UZ, VN, YU, ZW, ARIPO patent (GH, KE, LS, MW, SD, SZ, UG, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, CH, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, ML, MR, NE, SN, TD, TG). Published With international search report.
(54) Title: INVERTED STAMPING PROCESS ✓ (57) Abstract Printing of a pattern from a die to a surface is performed by immersing the die in a bath of liquid print material with the die surface facing upward, then either lowering the bath liquid level or raising the die to expose the die surface wet with liquid print material, and contacting the surface to be printed with the wet die surface.			